PTO/SB/47 (04-05)

Approved for use through 05/31/2006. OMB 0651-0016

U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless if displays a valid OMB control number.

Micron Technology, Inc.

Mail Stop 525

Mail Stop 525 8000 S. Federal Way, Boise, ID 83716-9632



Docket No.: M4065.0316/P316-A

(PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Examiner: Alexander G. Ghyka

Gurtej Sandhu, et al.

Application No.: 10/684,431

Art Unit: 2812

Filed: October 15, 2003

For: SEMICONDUCTOR DEVICES USING ANTI-REFLECTIVE COATINGS

## RESPONSE TO STATEMENT CONCERNING ALLOWABLE SUBJECT MATTER

Commissioner for Patents

MS: <u>Amendment</u>

P.O. Box 1450 . . . .

Alexandria, VA 22313-1450

Dear Sir:

This paper is in filed in response to the Allowable Subject Matter section of the January 31, 2006 Notice of Allowability mailed by the PTO.

While the applicant is in general agreement with the allowable subject matter section, the applicant notes the examiner left out the word "layer" from the statement. In other words the Notice of Allowability stated that "the prior art does not anticipate or make obvious an oxide formed" and should read "the prior art does not anticipate or make obvious an oxide layer formed."

Application No.: 10/684,431 Docket No.: M4065.0316/P316-A

Dated: May 01, 2006

Respectfully submitted,

Thomas J. D'Amico

Registration No.: 28,371

Steven War

Registration No.: 48,024

DICKSTEIN SHAPIRO MORIN &

**OSHINSKY LLP** 

2101 L Street NW

Washington, DC 20037-1526

(202) 785-9700

Attorneys for Applicants